

Annealsys partner of DIMENSION project

Montpellier, France, April 19, 2019

Recently TMDs monolayers such as MoS₂, MoSe₂, WS₂, and WSe₂ have emerged very promising as nanostructures for their potential applications in various fields: optics, electronics, catalysis and biosensors. The partners of the DIMENSION project are research laboratories in Montpellier (L2C, IEM) and Toulouse (CEMES, LAAS) as well as Annealsys.

In this project Annealsys will be developing deposition processes for Transition Metals Dichalcogenides (TMDs), while laboratories will work on characterization and applications of the layers. This project will allow Annealsys to extend its range of growth processes for 2D materials in addition to graphene and hexagonal boron nitride.

The DIMENSION project is financed by Region Occitanie.



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About Annealsys:

Founded in 2004 Annealsys and with more than 280 systems installed worldwide is a leading manufacturer of Rapid Thermal Processing and Direct Liquid Injection Deposition systems. We are supplying number of companies for the manufacturing of MEMS, sensors, optoelectronics, telecommunication, power and discrete devices. Many famous laboratories worldwide are using our machines for the development of future semiconductor, photovoltaic and nanotechnologies components. Our philosophy involves building up a long-term relationship with our customers, providing high reliability and high quality tools, insuring low cost of ownership and offering outstanding customer support and service. To achieve this, we have created a worldwide network with trained engineers for sales and service.

For more information visit Annealsys web site at www.annealsys.com/



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